

Erratum

A Compact Planar Magnetron Plasma Sputtering Device for TiO₂ Deposition – ERRATUM

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doi: 10.1557/opl.2013.1150, Published by Materials Research Society, 29 November 2013.

The article by Villamayor et al. was published with the incorrect volume number. The correct volume number is Volume 1601. The Materials Research Society and Cambridge University Press apologize to the authors for this error. The correct version of the article follows this notice.

Reference

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doi:10.1557/opl.2013.1150.